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(71) Applicant(s):

STRATASYS LTD. [IL/IL]; 1 Holtzman Street, Science Park P.O. Box 2496 7612401 Rehovot (IL) *(for all designated states)*

(72) Inventor(s):

GLASSMAN, Barak; 11 David Elazar Street 7402748 Nes Ziona (IL)

(74) Agent(s):

EHRlich, Gal; G. E. EHRlich (1995) LTD. 11 Menachem Begin Road, 5268104 Ramat-Gan (IL)

(54) Title (EN): METHOD AND SYSTEM FOR LEVELING A LAYER IN FREEFORM FABRICATION

(54) Title (FR): PROCÉDÉ ET SYSTÈME DE MISE À NIVEAU D'UNE COUCHE DANS UNE FABRICATION DE FORME LIBRE

(57) Abstract:

(EN): A method of fabricating an object in layers, comprises, for at least one layer: dispensing a building material formulation to form a first portion of the layer, and leveling the first portion by a leveling device; increasing a vertical distance between the first portion and the leveling device; and while a topmost surface of the first portion is exposed and beneath a segment of the leveling device: dispensing a building material formulation to form a second portion of the layer, laterally displaced from the first portion along an indexing direction, and leveling the second portion by the leveling device.

(FR): L'invention concerne un procédé de fabrication d'un objet en couches comprenant, pour au moins une couche : la distribution d'une formulation de matériau de construction pour former une première partie de la couche et la mise à niveau de la première partie par un dispositif de mise à niveau ; l'augmentation d'une distance verticale entre la première partie et le dispositif de mise à niveau ; et tandis qu'une surface la plus au-dessus de la première partie est exposée et en dessous d'un segment du dispositif de nivellement : la distribution d'une formulation de matériau de construction pour former une seconde partie de la couche, déplacée latéralement par rapport à la première partie le long d'une direction d'indexation, et la mise à niveau de la seconde partie par le dispositif de mise à niveau.

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